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(71) Applicant (for all designated States except US): **SCIENCE & TECHNOLOGY CORPORATION @ UNM**
[US/US]; 801 University Boulevard, S.E., Suite 101,
Albuquerque, New Mexico 87106 (US).

(72) Inventor; and

(75) Inventor/Applicant (for US only): **ENKE, Christie**
[US/US]; Placitas, New Mexico (US).

(74) Agent: **SANDBERG, Victoria, A.**; Muetting, Raasch
& Gebhardt, P.A., P.O. Box 581415, Minneapolis, MN
55458-1415 (US).

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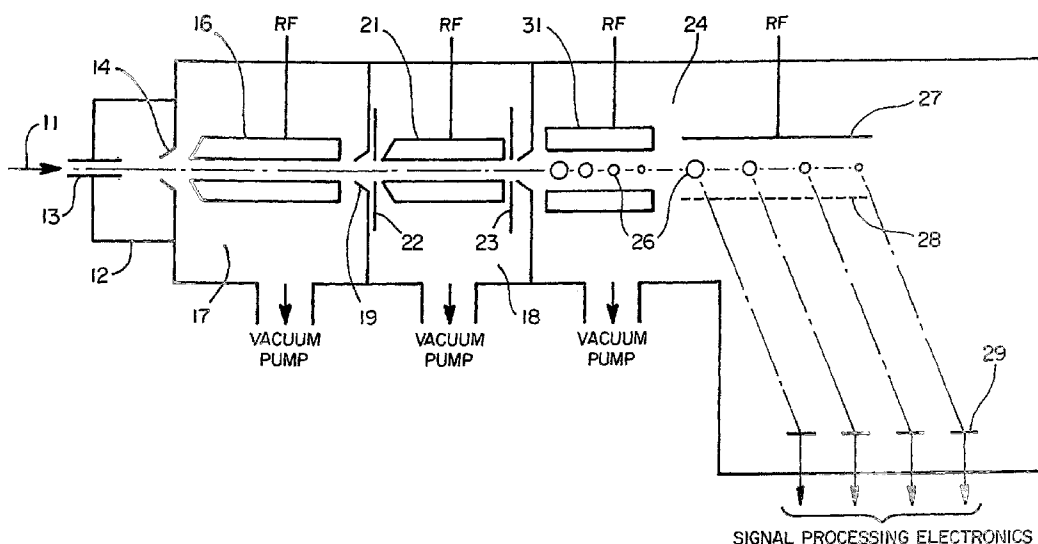
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[Continued on next page]

(54) Title: DISTANCE OF FLIGHT SPECTROMETER FOR MS AND SIMULTANEOUS SCANLESS MS/MS



(57) Abstract: A distance of flight (DOF) approach to mass spectroscopy in which the resolution among the various ion masses is accomplished in space rather than time. A separate detector is associated with each ion mass resolution element. The DOF mass spectrometer can serve as one element in a tandem arrangement which has the capability to produce a full two-dimensional precursor/product spectrum for each bunch of ions extracted from the source. A "distance-of-flight" (DOF) mass analyzer is used in combination with time-of-flight (TOF) mass analysis for precursor and product dispersion. All the precursor ions can undergo a mass changing reaction simultaneously, while still retaining the essential information about the particular precursor m/z value from which each product m/z value emanated. Through the use of a two-dimensional detector, all the products ions from all the precursors can be detected for each batch of ions analyzed.

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